

## CURRICULUM VITAE

Prof. Dr. Clemens Laubschat  
Institute of Solid-State and Materials Physics  
Technische Universität Dresden  
D-01062 Dresden

Tel: (0049) 351 4633 3249  
Fax: (0049) 351 4633 7173  
E-Mail: clemens.laubschat@tu-dresden.de

Education	1975-1980	Studies of physics and mathematics, Freie Universität Berlin
	1980	Diploma thesis: "Photoemission studies of intermetallic uranium compounds" (supervisor: Prof. Dr. G. Kaindl)
	1980-1984	PhD student, Institute for Atomic and Solid-State Physics, Freie Universität Berlin
	1984	PhD-thesis: "Photoemission and Bremsstrahlung-isochromat spectroscopy on heavy rare-earth compounds" (supervisor: Prof. Dr. G. Kaindl)
	1989	Habilitation in experimental physics

Employment	01.82-01.84	Scientific collaborator, Institute for Atomic and Solid-State Physics, Freie Universität Berlin
	04.84-03.90	Academic assistant (Hochschulassistent), Institute for Atomic Solid-State Physics, Freie Universität Berlin
	04.90-12.93	Senior academic assistant (Oberassistent), Institut for Atomic and Solid State Physics, Freie Universität Berlin
	since 12.93	Full professor of physics, Institute for Solid-State and Materials Physics, Technische Universität Dresden (TU Dresden)

Duties	12.93 - 08.06	Director of Institute for Surface and Microstructure Physics, TU Dresden
	07.96 - 12.08	Speaker of Collaborative Research Center CRC 463
	05.04 – 04.12	Member of Review Board 307 (Fachkollegium kond. Materie), German Research Foundation (DFG)
	09.06 - 11.09	Head of physics department (Prodekan Physik), TU Dresden
	12.09 –12.12	Director of Institute for Solid-State Physics, TU Dresden
	01.13 – 12.15	Head of physics department (Sprecher Physik), TU Dresden
	since 09.15	Member of Senate of TU Dresden

Research: Solid-state physics, bulk and surface phenomena in new materials.  
Method: Electron spectroscopy, particularly angle-resolved photoemission.  
Subjects: Strongly correlated electron systems, particularly rare-earths, actinides; thin film and surface phenomena; metal-metal and metal-semiconductor interfaces, carbon-derived materials, particularly doped and intercalated graphene.